PATENT 1794-0141P

IN THE U.S. PATENT AND TRADEMARK OFFICE

Applicant:

Yoshinobu AOYAGI et al. Conf.: 6758

Appl. No.:

09/941,612

Group: 1765

Filed:

August 30, 2001

Examiner: M. Song

For:

IMPURITY DOPING METHOD FOR SEMICONDUCTOR AS WELL AS SYSTEM THEREFOR AND SEMICONDUCTOR

MATERIALS PREPARED THEREBY

## LETTER TO THE OFFICIAL DRAFTSPERSON

Assistant Commissioner for Patents Washington, DC 20231

March 10, 2003

Sir:

Pursuant to the Office Action dated November 8, 2002, attached hereto is one (1) sheet of corrected Formal Drawings. Please substitute this corrected drawing for the corresponding Figure 2 currently on file in the above-identified application.

If necessary, the Commissioner is hereby authorized in this, concurrent, and future replies, to charge payment or credit any overpayment to Deposit Account No. 02-2448 for any additional fee required under 37 C.F.R. §§ 1.16 or 1.17; particularly, extension of time fees.

Respectfully submitted,

BIRCH, STEWART, KOLASCH & BIRCH, LLP

Joe McKinney Muncy, #32,334 2535

P.O. Box 747

Falls Church, VA 22040-0747

(703) 205-8000

1794-0141P ATTACHMENT

Rev. 09 00 00